Coupling of erbium-implanted silicon to a superconducting resonator

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Abstract

Erbium implanted silicon is promising for both photonic and quantum technology platforms, since it possesses both telecommunications and integrated circuit processing compatibility. However, several different Er centres are generated during the implantation and annealing process, the presence of which could hinder the development of these applications. When Si is co-implanted with 10^{17} cm⁻³ Er and 10^{20} cm⁻³ O ions, and the appropriate annealing process is used, one of these centres, which is present at higher Er concentrations, can be eliminated. Characterisation of samples with Er concentrations < 10^{17} cm⁻³ Er is limited by the sensitivity of standard electron paramagnetic resonance (EPR) instruments. The collective coupling strength between a superconducting (SC) NbN lumpedelement resonator and a 10^{17} cm⁻³ Er implanted Si sample at 20 mK was measured to be ~ 1 MHz, which provides a basis for the characterisation of low concentration er implanted Si and for future networks of hybrid quantum systems that exchange quantum information over the telecommunication network. Out of six known Er-related EPR centres, only one trigonal centre coupled to the SC resonator.

I. INTRODUCTION

When Er is co-implanted with O into Si, a variety of EPR and photoluminescence (PL) active centres can be observed. The PL active centres have been proposed as a platform for developing all-silicon photonic technology solutions that would eliminate the undesirable need for discrete direct bandgap semiconductor devices to interface with the fibre optic telecommunications network [1]. The EPR active centres have been proposed as a platform for developing quantum technologies (QTs) since using Er implanted Si links the decoupling from the environment of the partially filled 4f-shell inherent to all rare earths, with the integrated circuit fabrication pedigree of silicon [2,3]. We have recently reported an electron spin coherence time from Er implanted Si, with an Er concentration of 3×10^{17} cm⁻³, of 7.5 µs at 5 K [4], which compares to 1.6 µs at 1.9 K for ~2×10¹⁸ cm⁻³ Er: Y₂SiO₅[5] and ~5 μ s at 5 K for ~10¹⁶ cm⁻³ Er:CaWO₄[6]. This is promising given the difficulty in repairing defects after implantation that could lead to decoherence. To date, one of the main issues in the development of the photonic and quantum technology applications of Er implanted Si has been the difficulty in characterising, identifying and controlling the large number of EPR and PL active centres that are generated; a solution to this problem is offered through coupling the Er spin ensemble to a superconducting (SC) resonator, which can provide sensitivity enhancements over traditional EPR techniques. For example, by exploiting SC resonator coupling, the EPR signal from Er:Y₂SiO₅ can be detected with ~1 fW of microwave power [7] and the sensitivity for Bi spins in Si is 65 spins/ $\sqrt{\text{Hz}}$ [8].

As well as offering advantages for the EPR characterisation of a spin ensemble, the coupling of an SC resonator to a spin ensemble can itself constitute a hybrid quantum system with many advantages for quantum information processing over either individual system. If the interactions of a superconducting resonator coupled to a spin ensemble are mediated with one or a few superconducting qubits, a system possessing both the long coherence times of the spin ensemble and the fast gating of the superconducting qubits can be formed, in which case the hybrid quantum system can behave as a quantum Turing machine with the spin ensemble forming a microwave quantum memory and the SC qubits performing the gate operations [9,10]. The use of rare earths as a spin ensemble is beneficial because they generally possess large g factors as the orbital angular momentum is not quenched, which is advantageous for strong coupling [11], and long coherence times, which is

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advantageous for quantum memory [2]. The successful storage and on-demand retrieval of 16 weak coherent microwave pulses from Er: Y_2SiO_5 has been demonstrated [12], and a single ensemble could be used to store many qubits by using holographic encoding [13]. In addition, ensembles of rare earth ions coupled to SC resonators have been proposed for microwave-to-optical transducers for quantum networks [11,14]. The coherent conversion of single microwave to telecoms wavelength photons would allow applications such as optical fibre links between separate quantum processors and the deterministic entanglement of telecoms wavelength photons [15]. We have previously demonstrated that under 1.5 μ m illumination an EPR resonance from a PL active Er centre with orthorhombic symmetry in Er implanted Si can be observed which has an intensity three orders of magnitude higher than unilluminated EPR resonances [2]. This shows that the microwave and optical transitions required for various proposed microwave-to-optical transducer schemes involving rare earths[16,17] are present in a single Er centre in Er implanted Si. Other features that make Er implanted Si attractive for quantum information processing include the demonstration of deterministic single-ion implantation of rare earth ions with a placement precision of 34 nm [18].

Optical and magnetic characterisation of Er implanted Si presents a significant challenge in detecting a PL or EPR signal because of the relatively low number of Er centres compared to bulk, the low implant yield for any particular centre (the yield for all optically active Er centres varies between 1 and 10% for different studies [1]), and the indirect band gap of silicon. As such, EPR and PL characterisation is typically carried out with a high Er concentration, typcially10¹⁹ cm⁻³ [1,19]. Here we report EPR and PL from a sample with as low as 10¹⁷ cm⁻³ Er, and the first coupling between Er implanted in Si and a superconducting resonator, which could have applications in further characterisation and identification of the centres of Er implanted Si to enable quantum and photonic technology applications and in the development microwave quantum memory and microwave-to-optical transducers.

II. EXPERIMENTAL

Two samples, with Er concentrations of 10^{17} cm⁻³ and 10^{19} cm⁻³, both with O concentrations of 10^{20} cm⁻³, were prepared by implanting Er and O ions into <100> oriented 8000 ± 500 Ω cm Si wafer. Samples were then annealed at 620°C for 180 min anneal to recrystallize the amorphized region, then annealed at 850°C for 30 s to activate the Er; it was previously found that annealing at 850°C significantly increased the EPR signal strength [2]. For all samples, O and Er ions were implanted at a range of energies to give a flat concentration profile down to a depth of around 1.5 µm, see supplementary Figure S1 [20]. Isotope specific implantation was used so that only the zero nuclear spin ¹⁶⁶Er was implanted.

EPR measurements were performed in a Bruker E580 EPR spectrometer, with the magnetic field, B_0 , parallel to the [001] direction of the wafer with an uncertainty of $\pm 5^{\circ}$. All EPR measurements were made at 10 K, with a microwave frequency of 9.61 GHz, and a modulation width of 2 G. The microwave power used was 0.5 mW and 2.5 mW for the 10^{17} cm⁻³ Er and 10^{19} cm⁻³ Er samples, respectively. PL spectra were obtained by cooling the sample in a cold finger LN₂ cryostat at 65 K. Excitation was by a 462 nm 10 mW laser diode and the generated fluorescence was dispersed in a Bentham TMc300 monochromator, with a resolution of 1 nm, and detected with an IR photo multiplier tube coupled with standard phase sensitive detection.

SC resonator coupling measurements were performed in a dilution refrigerator, fitted with a vector magnet, at 20 mK. A superconducting lumped element micro-resonator was fabricated by sputtering 200 nm of NbN, patterned by standard e-beam lithography, onto an R-cut sapphire substrate. The 10^{17} cm⁻³ Er sample was "flip-chipped" on top of the micro-resonator and pressed down using Cu-Be springs. The micro-resonator was placed in a magnetic field that was stepped from zero to 930 G. The power in the resonator was ~3 pW. At each magnetic field the microwave transmission coefficient, S₂₁, was measured using a vector network analyser (VNA). This was repeated for magnetic field orientations between 0° and 160° in steps of 5°, with 0° corresponding to B₀ parallel to the face of the resonator and sample. The magnetic field was rotated around the [110] crystal axis of the sample. Numerical fitting of the S₂₁ response of the micro-resonator was used to extract the total measured loss tangent *tan* $\delta_{tot} = 1/Q_{tot}$, where Q_{tot} is the total measured Q factor and *tan* $\delta_{tot} = tan \delta_c + tan \delta_{diel} + 10^{17}$

 $tan \delta_{B} + tan \delta_{ions}$, are the loss tangents due to coupling to the transmission line, dielectric losses, the external magnetic field and the Er ions, respectively. Numerical fitting was used to extract $tan \delta_{ions}$. A discussion of the loss mechanisms is given in the supplementary information [20].

III. RESULTS AND DISCUSSION

A. EPR measurements

When implanted into Si, Er exists in its usual 3+ oxidation state [1]. Oxygen was co-implanted to a concentration of 10^{20} cm⁻³ for both samples and is required to generate narrow Er-related EPR [21] and PL [22] lines by the creation of various O coordinated Er centres. PL lines from a Si coordinated Er centre with cubic symmetry, Er-C, can be observed without O co-implantation [22]. PL lines from an O coordinated Er centre with orthorhombic C_{2v} symmetry, and an unidentified O coordinated Er centre, referred to as Er-O1R and PL-U, respectively, have been reported [2]. Previous measurements of the angular dependence of the Er-related EPR lines in Er implanted Si have identified a number of different O coordinated Er EPR centres: three monoclinic C_{1h} centres labelled OEr-1, OEr-1' and OEr-3, and three trigonal C_{3v} centres labelled OEr-2, OEr-2' and OEr-4 [19,21,23,24]. An unidentified EPR centre, EPR-U, with resonances ~1700 G, using the same B₀ orientation as us, has been reported [21]. Zeeman measurements of molecular-beam epitaxy (MBE) grown Er doped Si have identified an orthorhombic O coordinated Er centre [25], which is not EPR active and we have argued is the same centre as the Er-O1R we have previously identified [2]. A summary of all these centres, including their *g*-factors, are given in Table I. The isotropic *g*-factor for the cubic centre was calculated from crystal field analysis of the PL measurements [26].

Centre	Symmetry	Local Coordination	g _x	gy	gz	Ref.						
EPR active centres												
OEr-1	Monoclinic C _{1h}	0	0.8	5.45	12.6	[21]						
OEr-1'	Monoclinic C _{1h}	0	0.8	5.45	12.55	[21]						
OEr-3	Monoclinic C _{1h}	0	1.09	5.05	12.78	[21]						
OEr-4	Trigonal C _{3v}	0	2.0	6.23	6.23	[21]						
OEr-2	Trigonal C _{3v}	0	0.45	3.46	3.22	[21]						
OEr-2'	Trigonal C _{3v}	0	0.69	3.24	3.24	[21]						
EPR-U	-	0	-	-	-	[21]						
PL active centres												
Er-O1R	Orthorhombic C _{2v}	0	~0	~0	18.4	[2,25]						
Er-C	Cubic T _d	Si	6.8	-	-	[2,21,26]						
PL-U	-	0	-	-	-	[2]						

Table I Summary of the known EPR and PL active centres in Er implanted Si

Figure 1 shows the EPR spectra of the 10^{17} cm⁻³ Er and 10^{19} cm⁻³ Er samples. By comparison to the angular dependencies of the previously reported EPR centres in Table I we can assign a unique centre to all of the observed resonances. Note that a small angular deviation in the $[1\overline{10}]$ axis can cause significant shifting of the EPR resonances. The most intense resonances for both the 10^{17} cm⁻³ Er and 10^{19} cm⁻³ Er samples at ~925 G, attributed to the OEr-1 and OEr-3 monoclinic centres all have widths of ~5 G, whereas the resonances for both samples at ~2200 G, attributed to the OEr-2' trigonal centres all have widths of ~20 G. The independence of linewidth over such a large concentration range indicates that clustering does not affect the spin linewidth and therefore both centres are homogenously distributed. In Er:Y₂SiO₅ there are two Er centres with different *g*-factors; when coupled to a SC resonator it was found that the spin linewidth of the centre with a smaller *g*-factor was greater than the centre with a large *g*-factor; this was attributed to inhomogeneities in the DC magnetic field [27]. However, transitions with a larger *g*-factor are more susceptible to inhomogeneous spin linewidth. The

balance of these effects depends on alignment [27], which could explain the difference in EPR linewidth between the monoclinic and trigonal Er centres that we observed.



FIG 1 EPR spectra of 10¹⁷ cm⁻³ Er and 10¹⁹ cm⁻³ Er implanted Si. Resonances are assigned to the EPR centres in Table I, OEr-1, OEr-2' etc, as 1,2' etc, and U is the unidentified EPR centre. The microwave frequency was 9.61 GHz and the magnetic field was parallel to the [001] direction of the wafer.

B. Photoluminescence measurements

Figure 2 shows the PL spectra of the 10¹⁷ cm⁻³ Er and 10¹⁹ cm⁻³ Er samples. In the 10¹⁹ cm⁻³ Er spectrum we can identify peaks from the Er-C, the Er-O1R orthorhombic centre and PL-U unidentified centres [2] as indicated. The most intense peak at ~6510 cm⁻¹ can be attributed to both the Er-C and Er-O1R centres [2]. In the 10¹⁷ cm⁻³ Er spectrum no peaks unique to the Er-C centre can be identified, indicating that the Er-C centre is not present in the 10¹⁷ cm⁻³ Er sample. This indicates that the 1000:1 O:Er ratio in the 10¹⁷ cm⁻³ Er sample is effective in eliminating the Er-C Si coordinated centre because of the relative abundance of O. Additional peaks at 6450 and 6495 cm⁻¹ not observed

in the 10^{19} cm⁻³ Er spectrum can be identified, it cannot be determined at this stage if these originate from the same unidentified centre which gives peaks at > 6510 cm⁻¹.



FIG 2 PL spectra of 10¹⁷ cm⁻³ Er and 10¹⁹ cm⁻³ Er implanted Si at 65 K. PL peaks are assigned to the orthorhombic Er-O1R, cubic Er-C and unknow (PL-U) PL centres in Table I with arrows. The arrows are marked with 9, 7 or 9/7 if the peaks can be identified in the 10¹⁹ cm⁻³ Er spectrum, 10¹⁷ cm⁻³ Er spectrum or both spectra, respectively.

The PL linewidths are broadly similar for the 10^{17} cm⁻³ Er and 10^{19} cm⁻³ Er spectra: ~20 cm⁻¹ for the identifiable peaks. There are some small but significant shifts in the peak positions attributed to the orthorhombic centre of the 10^{17} cm⁻³ Er spectrum compared to the 10^{19} cm⁻³ Er spectrum, particularly the main peak at ~6510 cm⁻¹ and the highest energy orthorhombic peak at ~6570 cm⁻¹, which could represent a subtle change in the structure of this centre.

Crystal field analysis of rare earth spectra can be used to find crystal field parameters which measure the interaction between the *f*-shell electrons of rare earths and their surrounding crystalline

environment. Each possible symmetry of the rare earth's environment has its own set of CFPs. The Hamiltonian (H) of a rare earth in a magnetic field can be described as

$$H = H_F + H_{CF} + H_{Ze} \tag{1}$$

 H_F accounts for the interactions that occur in a free rare earth ion and is responsible for the energy of the J manifolds. Each rare earth has its own set of H_F parameters, which vary slightly between crystal hosts; those given by Carnall *et al.* for Er:LaF₃ were used here [28]. H_{CF} represents the perturbation generated by the ligands field surrounding a rare earth ion. The multipole expansion of H_{CF} is the linear combination of a set of spherical tensors, $C_q^{(k)}$, and a corresponding set of structural factors, B_q^k , which are the crystal field parameters.

$$H_{CF} = \sum_{k,q} B_q^k C_q^{(k)} \tag{2}$$

A description of the $C_q^{(k)}$ spherical tensor operator matrix can be found elsewhere [3]. Diagonalizing H_{CF} gives the crystal field energy levels of the *J* manifold. To find the CFPs we fitted CFPs that minimise the sum of squares difference between the calculated and experimental energy levels using the Levenberg-Marquardt algorithm. The Zeeman interaction, H_{Ze} , is given by

$$H_{Ze} = g_I \mu_B J. H \tag{3}$$

where g_J is the Landé factor, μ_B is the Bohr magneton, J is the angular momentum operator, and H is the magnetic field strength [29]. H_{Ze} was not considered during the fitting procedure. Once the Er³⁺ CFPs have been determined, the *g*-tensor for any crystal field doublet can be calculated from their eigenvectors, $|+\rangle$ and $|-\rangle$. The diagonal components of the *g*-tensor, g_x , g_y , g_z , can then be calculated from the first order perturbation expressions [29].

$$g_x = 2g_J \langle +|\boldsymbol{J}_x|-\rangle, \, g_y = 2g_J \langle +|\boldsymbol{J}_y|-\rangle, \, g_z = 2g_J \langle +|\boldsymbol{J}_z|+\rangle, \tag{4}$$

where J_x , J_y , J_z are the vector components of J such that $J^2 = J_x^2 + J_y^2 + J_z^2$.

We fitted the orthorhombic C_{2v} set of CFPs to the Er-O1R centre PL lines in Fig. 2; the PL lines <6200 cm⁻¹ could not be resolved in the 10^{17} cm⁻³ Er spectrum, so we used those from the 10^{19} cm⁻³ Er spectrum. We also used the hot line previously identified for this centre [22] to give the required number of crystal field levels to fit the nine orthorhombic C_{2v} CFPs, which are given in Table II.

	C _{2v} crystal field parameters (cm ⁻¹)										
Er conc.	B_0^2	B_0^4	B_{0}^{6}	B_{2}^{2}	B_{2}^{4}	B_4^4	B_{2}^{6}	B ⁶ ₄	B_{6}^{6}		
(cm ⁻³)											
10 ¹⁹	-72±3	-2085±36	3±7	159±6	-208±21	262±11	-260±7	-109±4	-30±10		
1017	-58±10	-1879±49	18±8	569±59	-258±38	214±24	-284±29	40±31	4±26		

Table II Fitted orthorhombic C_{2v} crystal field parameters for 10^{19} cm⁻³ Er and 10^{17} cm⁻³ Er PL.

To interpret the CFPs, recognising how the orthorhombic set of CFPs arises from progressive distortions of higher symmetry groups can be helpful. Cubic symmetry is described by four CFPs with constraints: $B_4^4 = 5B_0^4$ and $B_4^6 = -21B_0^6$ [30]. With a tetragonal distortion to a cubic field, the B_0^2 parameter appears, so it belongs only to the tetragonal component of the crystal field [31], and is therefore dependent on the degree of axial asymmetry. An orthorhombic distortion to a purely tetragonal field is described by addition of the B_2^2 , B_2^4 , B_2^6 and B_6^6 parameters. The calculated CFPs for the 10^{19} cm⁻³ Er spectrum are almost identical to what we have previously determined for 10^{19} cm⁻³ Er [2]; however, there are some important differences in the 10^{17} cm⁻³ Er CFPs. B_0^2 is smaller indicating there is less tetragonal distortion, whereas the magnitude of the four CFPs representing an orthorhombic distortion are all greater, except for B_6^6 , indicating a greater degree of orthorhombic distortion. Using the eigenvectors from our CFP fitting and Eq. 4 we calculated g-factors for 10^{17} cm⁻³ and 10^{19} cm⁻³ Er as $g_x \approx 0$, $g_y \approx 0$, $g_z = 17.6$ and $g_x \approx 0$, $g_y \approx 0$, $g_z = 17.9$, respectively, showing that any change in the structure of the Er-O1R at 10^{17} cm⁻³ Er has an insignificant effect on the g-factor.

C. Superconducting resonator coupling

The implanted face of the 10¹⁷ Er cm⁻³ sample was placed in contact with the superconducting NbN lumped-element micro-resonator on R-cut Al₂O₃ shown in Fig. 3a, which had a centre frequency $\omega_r/2\pi = 3.04$ GHz, see experimental section. Figure 3b shows the loss tangents due to coupling to Er ions (tan δ_{ions}) as function of B₀ and orientation. There is a single narrow resonance, with a FWHM of 50 ± 10 G, that varies smoothly between 740 and 870 G depending on the B₀ orientation. There is also a very broad resonance centred at 500 G and at $B_0 // [001]$ (0° orientation), the resonance shifts to 600 G at 50° B₀ orientation; we simulated the angular dependence of the six EPR centres (three trigonal, three monoclinic) previously identified Er and O implanted Si system [21], see Table I, but found no correspondence with this broad resonance. The narrow resonance had a correspondence with the trigonal OEr-2' centre identified in ref. [21] with $g_{\parallel} = 0.69$ and $g_{\perp} = 3.24$, which is shown in the simulation in Fig. 3c. The two other resonances are also visible in this B_0 range but are significantly weaker, which explains why only one resonance is observed in the micro-resonator measurement. A higher B₀ range shows the positions of all three expected EPR resonances with trigonal symmetry in the simulation in Fig. 3d. Only one previously identified OEr-2' trigonal centre is evident in the micro-resonator measurements at 20 mK; however, standard EPR measurements of the 10¹⁷ Er cm⁻³ at 10 K showed the presence of the OEr-1 monoclinic centre. This indicates that the spin-lattice relaxation time, T₁, of the OEr-1 centre is long enough at 20 mK to cause saturation of the coupling signal, but not for the OEr-2' centre.



FIG 3 a) Image of the SC resonator that was coupled to the 10^{17} cm⁻³ Er sample. The [110] direction of the sample which was placed on top of and covered the resonator is shown, along with the 0° and 90° directions of the magnetic field. b) Angular dependent micro-resonator EPR measurement at 20 mK. c) simulated angular dependent EPR spectrum using EASYSPIN numerical modelling for the trigonal OEr-2' centre identified by Carey *et al.* [21] with $g_1 = 0.69$ and $g_{\perp} = 3.24$. d) Simulated angular dependent EPR extended to higher B₀ to show the positions of the three expected EPR resonances with trigonal symmetry. The microwave frequency was 3.04 GHz for all micro-resonator measurements and simulations.

The Q factor of a resonator coupled to an ensemble of spins can be modelled as a single mode harmonic oscillator according to

$$Q_{tot} = \frac{\Delta^2 + \gamma^2}{2g_{col}^2 \gamma + \kappa(\Delta^2 + \gamma^2)} \omega_r, \tag{5}$$

where Δ is the detuning from the spin resonance peak, γ is the spin linewidth, κ is the cavity linewidth = $2\pi\omega_r/Q_{tot} = 0.56$ MHz for the 0° orientation and was independently measured away from the resonance for each B₀ orientation, Q_{tot} is the total measured cavity Q, and g_{col} is the collective coupling strength. Figure 4 shows the fitting of Eq. 5 to the Q_{tot} for the 0° orientation which gives g_{col}/2 π = 1 MHz and $\gamma/2\pi$ = 80 MHz. The average for all B₀ orientations was g_{col}/2 π = 1.1 ± 0.3 MHz and $\gamma/2\pi$ =

 85 ± 25 MHz. The coupling strength of an individual spin to the SC resonator is given by $g_i = g_{col}/\sqrt{N}$, where N is the number of spins coupled to the resonator; using the number of Er ions above the inductive element (Er dose \times inductive element area = 3.7×10^{10}) gives a lower limit for g_i of ~ 6 Hz, since the implantation yield is unknown for this EPR centre. This compares to $g_i \sim 70$ Hz for Er implanted Y₂SiO₅ crystal [14]. We calculated the expected collective coupling strength g_{col,calc} by numerically simulating, then integrating over, the magnetic field and implanted ion distributions. Details of this simulation are given in the supplementary information [20], and further details can be found in refs.[32-36]. Our numerical simulation provided $g_{col,calc} \sim 3$ MHz, which is, to a first approximation, consistent with the measured g_{col} and similar to what we have calculated previously for Gd implanted Al₂O₃ coupled to a micro-resonator [37]. We observed no change in ω_r as B₀ was swept through the Er spin resonance, indicating the system is operating in the weak coupling regime. The signal to noise ratio (SNR) was calculated from $SNR = (A_{signal} / A_{noise})^2$, where A_{signal} and A_{noise} are the signal and noise amplitudes, respectively. For the microresonator EPR measurement shown in Figure 4 the SNR was 140±30, this compares a SNR of 5±2 for the EPR spectrum of the same OEr-2' centre, with a similar sweep time. Our micro-resonator measurement represents the first reported coupling of a SC resonator to a rare earth ensemble implanted in Si, and a significant improvement in SNR compared to standard EPR.



FIG 4. Measured Q factor with the baseline subtracted of the micro-resonator EPR measurement with a field orientation of 0° with a fit using Eq. 5. Inset shows the total measured Q factor without baseline subtraction.

IV. CONCLUSIONS

When Er concentration is reduced from 10^{19} cm⁻³ to 10^{17} cm⁻³, but the O concentration is kept at 10^{20} cm⁻³, no change in EPR linewidth was observed, indicating concentration effects are not important. The Si coordinated Er centre with cubic symmetry is no longer evident in PL measurements. Some small PL peak shifts of the O coordinated Er centre with orthorhombic symmetry were observed at 10^{17} cm⁻³ Er. Crystal field analysis of these PL peaks indicated that the orthorhombic Er centre has less tetragonal distortion, but greater orthorhombic distortion at 10^{17} cm⁻³ Er. Reducing Er concentration while keeping a relatively high O concentration may be an effective strategy to further reduce the numerous Er centres that are generated; however, detecting by standard EPR techniques presents a challenge to characterising at low concentrations, a solution could be to exploit SC resonator coupling. We observed the first coupling between a SC resonator and Er implanted Si with $g_{col} = 1$ MHz and $g_i > 6$ Hz, which provides a basis for characterisation of low concentration Er implanted Si and for future networks of hybrid quantum processors that exchange quantum information over the telecommunication network. Numerical simulation indicated an expected g_{col} of ~ 3 MHz. Out of six known Er-related EPR centres, only one trigonal centre coupled to the SC resonator at 20 mK.

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Author Contributions

The concept was developed by MAH. Experimental work was performed by MAH, NAP, MU, NT and IW with input from JDC and TL. The manuscript was written by MAH with editorial input from JDC, KPH and BM. All authors contributed to analyzing the results and commented on the paper.

Data availability

The datasets generated during the current study are available in the Mendeley Data repository at http://dx.doi.org/10.17632/stpfvbp8yc.1